

Title (en)
ELECTRICALLY CONDUCTIVE BASE PLATE AND A PRODUCTION METHOD FOR THE SAME

Title (de)
ELEKTRISCH LEITENDE BASISPLATTE UND HERSTELLUNGSVERFAHREN DAFÜR

Title (fr)
PLAQUE DE BASE CONDUCTRICE DE L ÉLECTRICITÉ ET PROCÉDÉ DE FABRICATION ASSOCIÉ

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Abstract (en)
The present disclosure discloses a conductive substrate with a conductive pattern formed on a float glass and a method for manufacturing the same, which can prevent a yellowing phenomenon from occurring in the float glass during firing of the conductive substrate. The method for manufacturing the conductive substrate according to the present disclosure includes manufacturing a float glass by injecting molten glass onto a molten tin contained in a float bath, removing a top face of the float glass not contacting the molten tin, by a predetermined thickness, and forming a conductive pattern on the top face of the float glass, which was removed by a predetermined thickness.

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